

COMBINED DECLARATION AND POWER OF ATTORNEY

As below named inventor, I hereby declare that

This declaration is of the following type:

- ☒ original ☐ design ☐ supplemental
☐ national stage of PCT
☐ divisional ☐ continuation ☐ continuation-in-part

My residence, post office address, and citizenship are as stated below next to my name. I believe I am the original, first, and sole inventor (*if only one name is listed below*) or an original, first, and joint inventor (*if plural names are listed below*) of the subject matter which is claimed and for which a patent is sought on the invention entitled:

CITALOPRAM HYDROBROMIDE CRYSTAL AND

METHOD FOR CRYSTALLIZATION THEREOF

the specification of which:

- ☒ is attached hereto.
☐ was filed on _____ as Application No. _____ and was amended on _____ (*if applicable*).
☐ was filed by Express Mail No. _____, as Application No. not known yet, and was amended on _____ (*if applicable*).
☐ was described and claimed in PCT International Application No. _____ filed on _____ and as amended pursuant to PCT Article 19 on _____ (*if any*).

I state that I have reviewed and understand the contents of the above-identified specification, including the claim(s), as amended by any amendment referred to above.

I acknowledge the duty to disclose information that is material to the patentability of this application in accordance with 37 C.F.R. § 1.56.

I claim foreign priority benefits under 35 U.S.C. § 119 of any foreign application(s) for patent or inventor's certificate or of any PCT international application(s) designating at least one country other than the United States of America listed below and have also identified below any foreign application(s) for patent, utility model, design registration, or inventor's certificate or any PCT international application(s) designating at least one country other than the United States of America filed by me on the same subject matter having a filing date before that of the application(s) of which priority is claimed.

| PRIOR FOREIGN PATENT, UTILITY MODEL, AND DESIGN REGISTRATION APPLICATIONS | | | | | | |
|---|-------------|------------------------------------|---|-----|--|----|
| COUNTRY | APPLICATION | DATE OF FILING (day,month,year) | PRIORITY CLAIMED UNDER 35 U.S.C. § 119 | | | |
| Japan | 133995/2000 | 02/05/2000 | X | YES | | NO |
| | | | | YES | | NO |
| | | | | YES | | NO |

I claim the benefit pursuant to 35 U.S.C. § 119(e) of the following United States provisional application(s):

| PRIOR U.S. PROVISIONAL APPLICATIONS BENEFIT CLAIMED UNDER 35 U.S.C. 119(e) | |
|---|------------------------------------|
| APPLICATION NO. | DATE OF FILING (day,month,year) |
| | |
| | |
| | |

I claim the benefit pursuant to 35 U.S.C. § 120 of any United States application(s) or PCT international application(s) designating the United States of America listed below and, insofar as the subject matter of each of the claims of this application is not disclosed in that/those prior application(s) in the manner provided by the first paragraph of 35 U.S.C. § 112, I acknowledge the duty to disclose material information as defined in 37 C.F.R. § 1.56 effective between the filing date of the prior application(s) and the national or PCT international filing date of this application.

| PRIOR U.S. APPLICATIONS OR PCT INTERNATIONAL PATENT APPLICATIONS DESIGNATING THE U.S. FOR BENEFIT UNDER 35 U.S.C. 120 | | | | | |
|--|--|--|--------------------|-----------|-----------|
| U.S. APPLICATIONS | | | Status (check one) | | |
| APPLICATION NO. | U.S. FILING DATE | PATENTED | PENDING | ABANDONED | |
| 1. 0 / | | | | | |
| 2. 0 / | | | | | |
| 3. 0 / | | | | | |
| PCT APPLICATIONS DESIGNATING THE U.S. | | | Status (check one) | | |
| PCT APPLICATION NO. | PCT FILING DATE (day,month,year) | U.S. APPLN. NOS. ASSIGNED (if any) | PATENTED | PENDING | ABANDONED |
| 4. | | | | | |
| 5. | | | | | |
| 6. | | | | | |

| DETAILS OF FOREIGN APPLICATIONS FROM WHICH PRIORITY CLAIMED UNDER 35 U.S.C. §119 FOR ABOVE LISTED U.S./PCT APPLICATIONS | | | | |
|--|---------|-----------------|------------------------------------|-----------------------------------|
| ABOVE APPLN. NO. | COUNTRY | APPLICATION NO. | DATE OF FILING (day,month,year) | DATE OF ISSUE (day,month,year) |
| 1. | | | | |
| 2. | | | | |
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| 4. | | | | |
| 5. | | | | |
| 6. | | | | |

As a named inventor, I hereby appoint Leydig, Voit & Mayer, Ltd. to prosecute this application and transact all business in the Patent and Trademark Office connected therewith: Customer Number 23460.



23460

PATENT TRADEMARK OFFICE

I further direct that correspondence concerning this application be directed to Leydig, Voit & Mayer, Ltd.: Customer Number 23460.



23460

PATENT TRADEMARK OFFICE

I declare that all statements made herein of my own knowledge are true, that all statements made on information and belief are believed to be true, that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code, and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

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DECLARATION_BLANK_CUSTNO (Rev. 5/4/2000)